

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Helen H. ZHU et al.

Application No.: 09/820,694

Filed: March 30, 2001

For: METHOD OF PLASMA ETCHING
SILICON NITRIDE

)
) Group Art Unit: XX

)
) Examiner: Unassigned

INFORMATION DISCLOSURE STATEMENT
TRANSMITTAL LETTER

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

Enclosed is an Information Disclosure Statement and accompanying form PTO-1449 for the above-identified patent application.

- ☒ No additional fee for submission of an IDS is required.
- ☐ The fee of \$180.00 (126) as set forth in 37 C.F.R. § 1.17(p) is also enclosed.
- ☐ A certification under 37 C.F.R. § 1.97(e) is also enclosed.
- ☐ A certification under 37 C.F.R. § 1.97(e), and the fee of \$180.00 (126) as set forth in 37 C.F.R. § 1.17(p) are also enclosed.
- ☐ Charge \$_____ to Deposit Account No. 02-4800 for the fee due.
- ☐ A check in the amount of \$_____ is enclosed for the fee due.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

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By: Peter K. Skiff
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Registration No. 31,917

Date: July 12, 2001

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INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In accordance with the duty of disclosure as set forth in 37 C.F.R. § 1.56, Applicants hereby submit the following information in conformance with 37 C.F.R. §§ 1.97 and 1.98.

Pursuant to 37 C.F.R. § 1.98, a copy of each of the documents cited is enclosed.

U.S. Patent No. 5,611,888, Bosch et al., issued March 18, 1997

U.S. Patent No. 5,786,276, Brooks et al., issued July 28, 1998

U.S. Patent No. 5,790,365, Shel, issued August 4, 1998

U.S. Patent No. 5,820,723, Benjamin et al., issued October 13, 1998

U.S. Patent No. 6,057,244, Hausmann et al., issued May 2, 2000

U.S. Patent No. 6,090,304, Zhu et al., issued July 18, 2000

U.S. Patent No. 6,143,641, Kitch, issued November 7, 2000

U.S. Patent No. 6,153,514, Wang et al., issued November 28, 2000

U.S. Patent No. 6,156,642, Wu et al., issued December 5, 2000

European Patent No. 0908940, issued April 14, 1999

The documents are being submitted within 3 months of the filing or entry of the national stage of this application or before the first Office Action on the merits, whichever is later, therefore no fee or certification is required under 37 C.F.R. § 1.97(b).

To assist the Examiner, the documents are listed on the attached form PTO-1449. It is respectfully requested that an Examiner initialed copy of this form be returned to the undersigned.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

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